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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/533,020	04/27/2005 Carl Glasse		1217/207	1660	
46852 LIU & LIU	7590 11/26/200)	EXAMINER		
444 S. FLOWE LOS ANGELE	ER STREET, SUITE 1750		TAYLOR, EARL N		
LOS ANGELE	5, CA 900/1		ART UNIT	PAPER NUMBER	
			2818		
			MAIL DATE	DELIVERY MODE	
			11/26/2008	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Communication		A	pplication No.	lication No. Applicant(s)				
		1	0/533,020		GLASSE ET AL.			
Office Action Summary			xaminer		Art Unit			
		E/	ARL N. TAYLOR		2818			
Period fo	The MAILING DATE of this commun or Reply	ication appear	s on the cover shee	et with the co	orrespondence ad	ldress		
WHIC - Exter after - If NC - Failu Any (ORTENED STATUTORY PERIOD F CHEVER IS LONGER, FROM THE M nsions of time may be available under the provisions SIX (6) MONTHS from the mailing date of this comr o period for reply is specified above, the maximum st re to reply within the set or extended period for reply reply received by the Office later than three months and patent term adjustment. See 37 CFR 1.704(b).	MAILING DATE s of 37 CFR 1.136(a) nunication. atutory period will ap will, by statute, caus	E OF THIS COMMU In no event, however, ma pply and will expire SIX (6) se the application to become	JNICATION ay a reply be time MONTHS from to the ABANDONED	l. ely filed he mailing date of this c) (35 U.S.C. § 133).			
Status								
1) 又	Responsive to communication(s) file	ed on 12 Sente	ember 2008					
2a)□	·		tion is non-final.					
3)		<i>'</i> —		natters, pro	secution as to the	e merits is		
٠,٠	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims							
4)🛛)⊠ Claim(s) <u>9-17 and 20-30</u> is/are pending in the application.							
	4a) Of the above claim(s) is/are withdrawn from consideration.							
	☐ Spare wither awn from consideration. ☐ Claim(s) 16,17 and 20-27 is/are allowed.							
· · · · · · · · · · · · · · · · · · ·	S)⊠ Claim(s) <u>9-13 and 28-30</u> is/are rejected.							
· · · —	Claim(s) <u>14 and 15</u> is/are objected t							
•	Claim(s) are subject to restriction and/or election requirement.							
Applicati	on Papers							
9)□	The specification is objected to by th	e Examiner.						
•	The drawing(s) filed on is/are		ed or b)∏ objected	to by the E	xaminer.			
,	Applicant may not request that any obje		· -	=				
				-		FR 1.121(d).		
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.								
Priority ι	ınder 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
2) Notic 3) Inform	t(s) e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (F mation Disclosure Statement(s) (PTO/SB/08) r No(s)/Mail Date	PTO-948)	Paper 5) Notice	iew Summary (No(s)/Mail Da e of Informal Pa				

DETAILED ACTION

Response to Arguments

Applicant's arguments, see page 9, filed 12 September 2008, with respect to the rejection(s) of claim(s) 13 under 35 U.S.C. 102(b) have been fully considered and are persuasive. Therefore, the rejection has been withdrawn. However, upon further consideration, a new ground(s) of rejection is made in view of Yamazaki et al. (U.S. Patent 6,501,098 B2).

Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 28-30 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 28-30 recites the claim language "so that the fillet remains within the TFT finally formed". The scope of the claim language is vague and indefinite. At best it is unclear when is the TFT finally formed. Furthermore, Claim 29 recites the claim language "further comprising the step of retaining the fillet…"; this does not constitute a positive recitation of performing a step. The manner in which the claims are written does not define when the TFT is finally formed; could the TFT be finally formed the moment step (d) is completed while the fillet is still present? The examiner suggests

when responding to clarify these issues to be aware of adding negative limitations as new matter can be potentially introduced.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 13 are rejected under 35 U.S.C. 102(b) as being anticipated by Yamazaki et al. (U.S. Patent 6,501,098 B2) hereinafter referred to as "Yamazaki".

Referring to Claim 13, Yamazaki teaches, in Fig. 3A-3C and 8A a method of fabricating a polycrystalline silicon channel TFT with a gate overlying the channel, having an upstanding gate side wall, the method comprising the steps of:

- (a) providing a gate (308 and 309) separated from a polycrystalline silicon layer (303) by an insulating layer (306) (Fig. 3A);
- (b) implanting a dopant into the polycrystalline silicon layer (303) using the gate (308 and 309) as a mask (Col. 13, Lines 25-45; Fig. 3B);
- (c) forming a spacer layer (856; Fig. 8A) after step (b) adjacent to the gate (308 and 309) that comprises a conductive region which overlies the polycrystalline silicon layer (303) and extends along the gate (308 and 309) side wall, comprising depositing a layer of conductive material (321; Fig. 3C) over the polycrystalline silicon layer (303)

and the gate (308 and 309), and selectively etching the deposited layer of conductive material (321) to form the spacer (856) with a first portion overlying the polycrystalline silicon layer (303) and a second portion extending along on the side wall of the gate (309), wherein the selective etching of the conductive layer (321) is carried out by forming a fillet (resist mask 801) over the first portion thereof, and selectively etching the conductive layer (321) where not protected by the fillet (801); and

(d) implanting a dopant into the polycrystalline silicon layer (303) using the gate (308 and 309) and the spacer (856) as a mask to form a source or drain region (806 and 807), such that the spacer (856) overlies an LDD region in the polycrystalline silicon layer (303) between the source or drain region and the channel (Fig. 8A) (Col. 17, Lines 61-77 and Col. 18, Lines 15-23). Yamazaki teaches that the fillet (resist mask 801) is formed and the spacer (conductive layer 321) is partly removed by etching before the second doping step shown in Fig. 8A.

Referring to Claim 9, Yamazaki further teaches depositing the layer of conductive material (321) to a thickness which is less than that of the gate (308 and 309).

Referring to Claims 10 and 11, Yamazaki further teaches depositing the layer of conductive material (321) by sputtering to form a non-conformal layer (Col. 13, Line 58).

Referring to Claim 12, Yamazaki further teaches depositing said layer of conductive material (321) as a metallic layer (51-55; Col. 11, Lines 1-2).

As insofar as claims 29 and 30 are definite, Yamazaki further teaches all of the claimed method steps wherein the moment the implantation of step (d) is finished the fillet is still present thus all of the method limitations are met at that moment. Therefore

since all of the positively recited claimed steps have been taught the TFT must have been finally formed.

Allowable Subject Matter

Claims 16, 17 and 20-27 are allowable.

Claim 14 objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter:

Regarding Claim 14, the prior art of record alone or in combination neither teaches nor makes obvious the invention of selectively etching the further layer to form the fillet therefrom in combination with all of the limitations of Claims 13 and 14.

Regarding Claim 16, the prior art of record alone or in combination neither teaches nor makes obvious the invention of depositing a further layer as a Si containing layer on the conductive layer and selectively etching the further layer to form the fillet therefrom in combination with all of the limitations of Claim 16.

Regarding Claim 17, the prior art of record alone or in combination neither teaches nor makes obvious the invention of depositing a further layer by CVD on the conductive layer and selectively etching the further layer to form the fillet therefrom in combination with all of the limitations of Claim 17.

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Telephone / Fax Information

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Earl N. Taylor whose telephone number is (571) 272-

8894. The examiner can normally be reached on Monday-Friday from 8:30AM-5:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Steven Loke can be reached on (571) 272-1657. The fax phone number for

the organization where this application or proceeding is assigned is (571) 273-8300.

Information regarding the status of an application may be obtained from the

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Business Center (EBC) at 866-217-9197 (toll-free).

Examiner: Earl N. Taylor

/DAVID_VU/

Primary Examiner, Art Unit 2818